



PATENT

**IN THE UNITED STATES PATENT
AND TRADEMARK OFFICE**

Applicants: Jung et al.

Serial No.: 10/789,055

Filed: February 27, 2004

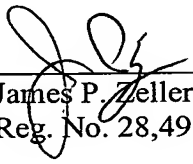
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Group Art Unit: 1752

Examiner: Sin J. Lee

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RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Please amend this application as follows:

the amendments to the claims section begins on page 2 of this paper;

the remarks section begins on page 7 of this paper.